L Number	Hits	Search Text	DB	Time stamp
1	27940	((amorphous non/crystal\$5) near5 silicon)	USPAT;	2003/07/05 12:14
1			US-PGPUB	
2	9972	(((amorphous non/crystal\$5) near5	USPAT;	2003/07/05 12:08
1.		silicon)) and oxygen	US-PGPUB	
] 3	11549	(((amorphous non/crystal\$5) near5	USPAT;	2003/07/05 12:14
1		silicon)) and (oxygen O2 "O.sub.2")	US-PGPUB	
4	10797	(((amorphous non/crystal\$5) near5	USPAT;	2003/07/05 12:15
1	1	silicon)) and (nitrogen N2 "N.sub.2")	US-PGPUB	
5	11897	(((amorphous non/crystal\$5) near5	USPAT;	2003/07/05 12:15
1		silicon)) and (hydrogen H2 "H.sub.2")	US-PGPUB	
6	17464	((((amorphous non/crystal\$5) near5	USPAT;	2003/07/05 12:09
1	}	silicon)) and (oxygen 02 "0.sub.2"))	US-PGPUB	1
1	}	((((amorphous non/crystal\$5) near5		
		silicon)) and (nitrogen N2 "N.sub.2"))		
	ĺ	((((amorphous non/crystal\$5) near5		1
	1	silicon)) and (hydrogen H2 "H.sub.2"))		
7	14502	(((((amorphous non/crystal\$5) near5	USPAT;	2003/07/05 12:16
	1	silicon)) and (oxygen O2 "O.sub.2"))	US-PGPUB	
		((((amorphous non/crystal\$5) near5	1	
	}	silicon)) and (nitrogen N2 "N.sub.2"))		1
		((((amorphous non/crystal\$5) near5		
		silicon)) and (hydrogen H2 "H.sub.2")))		
		and (anneal\$3 heat\$3 cryatalliz\$3)		
8	14639	(((((amorphous non/crystal\$5) near5	USPAT;	2003/07/05 12:11
1	ļ	silicon)) and (oxygen O2 "O.sub.2"))	US-PGPUB	
1		((((amorphous non/crystal\$5) near5		
	1	silicon)) and (nitrogen N2 "N.sub.2"))		
	-	((((amorphous non/crystal\$5) near5		
1	Į	silicon)) and (hydrogen H2 "H.sub.2")))	1	
		and (anneal\$3 heat\$3 crystalliz\$3)		
9	2160	((((((amorphous non/crystal\$5) near5	USPAT;	2003/07/05 12:18
	1	silicon)) and (oxygen O2 "O.sub.2"))	US-PGPUB	
	ļ	((((amorphous non/crystal\$5) near5	1	
1		silicon)) and (nitrogen N2 "N.sub.2"))	}	
		((((amorphous non/crystal\$5) near5		
	ĺ	silicon)) and (hydrogen H2 "H.sub.2")))		
1	ł	and (anneal\$3 heat\$3 crystalliz\$3)) and	}	
1	ļ	((anneal\$3 heat\$3 crystalliz\$3) near100	j	
1		silicon near100 (environment gas		
1		atmosphere))		
10	5425		USPAT;	2003/07/05 12:18
	j	silicon)) and (oxygen O2 "O.sub.2"))	US-PGPUB	
		((((amorphous non/crystal\$5) near5		
	ĺ	silicon)) and (nitrogen N2 "N.sub.2"))		
	1	((((amorphous non/crystal\$5) near5	1	
	l	silicon)) and (hydrogen H2 "H.sub.2")))	1	
1		and (anneal\$3 heat\$3 crystalliz\$3)) and	-	
1	1	((anneal\$3 heat\$3 crystalliz\$3) same		
1		silicon same (environment gas atmosphere))	1	
11	5425	(((((((amorphous non/crystal\$5) near5	USPAT;	2003/07/05 12:12
1		silicon)) and (oxygen 02 "0.sub.2"))	US-PGPUB	
1	1	((((amorphous non/crystal\$5) near5		
	1	silicon)) and (nitrogen N2 "N.sub.2"))	1	[
	Į	((((amorphous non/crystal\$5) near5	1	1
		silicon)) and (hydrogen H2 "H.sub.2")))	1	
		and (anneal\$3 heat\$3 crystalliz\$3)) and		
1	(((anneal\$3 heat\$3 crystalliz\$3) near100	1	
1	ł	silicon near100 (environment gas	1	
1]	atmosphere))) ((((((amorphous	1	
		non/crystal\$5) near5 silicon)) and (oxygen		
		02 "0.sub.2")) ((((amorphous	1	
1	1	non/crystal\$5) near5 silicon)) and	1	
1)	(nitrogen N2 "N.sub.2")) ((((amorphous	,	
		non/crystal\$5) near5 silicon)) and		
		(hydrogen H2 "H.sub.2"))) and (anneal\$3	1	
1		heat\$3 crystalliz\$3)) and ((anneal\$3		
1)	heat\$3 crystalliz\$3) same silicon same (environment gas atmosphere)))		

			,	
14	1698	(((((((((amorphous non/crystal\$5) near5 silicon)) and (oxygen 02 "0.sub.2"))	USPAT; US-PGPUB	2003/07/05 12:19
		((((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2"))		
		((((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")))		
	1	and (anneal\$3 heat\$3 crystalliz\$3)) and	1	
		((anneal\$3 heat\$3 crystalliz\$3) near100 silicon near100 (environment gas		
		atmosphere))) ((((((amorphous	1	
		non/crystal\$5) near5 silicon)) and (oxygen 02 "0.sub.2")) ((((amorphous		
		non/crystal\$5) near5 silicon)) and	1	
		(nitrogen N2 "N.sub.2")) ((((amorphous non/crystal\$5) near5 silicon)) and		
		(hydrogen H2 "H.sub.2"))) and (anneal\$3		
		heat\$3 crystalliz\$3)) and ((anneal\$3 heat\$3 crystalliz\$3) same silicon same		
		(environment gas atmosphere)))) and ((TFT (thin near3 film near3 transitor)))		
15	22106	((amorphous non/crystal\$5) near5 silicon)	EPO; JPO;	2003/07/05 12:14
			DERWENT; IBM TDB	
16	1507	(((amorphous non/crystal\$5) near5	EPO; JPO;	2003/07/05 12:15
	-	silicon)) and (oxygen 02 "0.sub.2")	DERWENT; IBM TDB	
17	555	((((amorphous non/crystal\$5) near5	EPO; JPO;	2003/07/05 12:15
		silicon)) and (oxygen 02 "0.sub.2")) and (nitrogen N2 "N.sub.2")	DERWENT; IBM TDB	}
18	1449	(((amorphous non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")	EPO; JPO; DERWENT;	2003/07/05 12:15
			IBM_TDB	1
19	2627	(((amorphous non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2")	EPO; JPO; DERWENT;	2003/07/05 12:16
			IBM_TDB	0000105105 10 15
20	4478	((((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2"))	EPO; JPO; DERWENT;	2003/07/05 12:16
		(((((amorphous non/crystal\$5) near5	IBM_TDB	
	1	silicon)) and (oxygen O2 "O.sub.2")) and (nitrogen N2 "N.sub.2")) ((((amorphous		
		non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) ((((amorphous	1	
		non/crystal\$5) near5 silicon)) and	1	
22	1265	(((((amorphous non/crystal\$5) near5	EPO; JPO;	2003/07/05 12:16
	1200	silicon)) and (oxygen 02 "0.sub.2"))	DERWENT;	
		(((((amorphous non/crystal\$5) near5 silicon)) and (oxygen 02 "0.sub.2")) and	IBM_TDB	
		(nitrogen N2 "N.sub.2")) ((((amorphous	1	
		non/crystal\$5) near5 silicon)) and (nitrogen N2 "N.sub.2")) ((((amorphous	1	
		non/crystal\$5) near5 silicon)) and (hydrogen H2 "H.sub.2"))) and (anneal\$3	1	
		heat\$3 cryatalliz\$3)		
24	600	(((((((amorphous non/crystal\$5) near5 silicon)) and (oxygen O2 "O.sub.2"))	EPO; JPO; DERWENT;	2003/07/05 12:18
		(((((amorphous non/crystal\$5) near5	IBM_TDB	
		silicon)) and (oxygen 02 "0.sub.2")) and (nitrogen N2 "N.sub.2")) ((((amorphous		
		non/crystal\$5) near5 silicon)) and	1	
		(nitrogen N2 "N.sub.2")) ((((amorphous non/crystal\$5) near5 silicon)) and	1	
		(hydrogen H2 "H.sub.2"))) and (anneal\$3 heat\$3 cryatalliz\$3)) and ((anneal\$3	1	1
	1	heat\$3 crystalliz\$3) same silicon same	1	
		(environment gas atmosphere))	L	L

25	37	(((((((amorphous non/crystal\$5) near5	EPO; JPO;	2003/07/05 12:19
		silicon)) and (oxygen 02 "0.sub.2"))	DERWENT;	
		(((((amorphous non/crystal\$5) near5	IBM TDB	
		silicon)) and (oxygen 02 "0.sub.2")) and	_	
		(nitrogen N2 "N.sub.2")) ((((amorphous		
		non/crystal\$5) near5 silicon)) and		
		(nitrogen N2 "N.sub.2")) ((((amorphous		
		non/crystal\$5) near5 silicon)) and		
		(hydrogen H2 "H.sub.2"))) and (anneal\$3		
		heat\$3 cryatalliz\$3)) and ((anneal\$3		
		heat\$3 crystalliz\$3) same silicon same		
		(environment gas atmosphere))) and ((TFT		
		(thin near3 film near3 transitor)))		